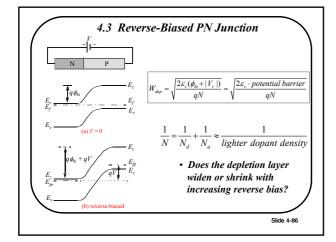
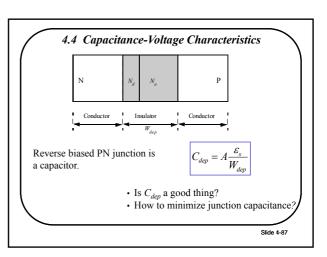
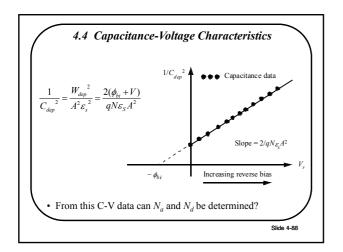


EXAMPLE: A P+N junction has  $N_a = 10^{20} \, \mathrm{cm}^{-3}$  and  $N_d = 10^{17} \, \mathrm{cm}^{-3}$ . What is a) its built in potential, b)  $W_{dep}$ , c) $x_N$ , and d)  $x_P$ ?

Solution:
a)  $\phi_{bi} = \frac{kT}{q} \ln \frac{N_d N_a}{n_i^2} = 0.026 \, \mathrm{V} \ln \frac{10^{20} \times 10^{17} \, \mathrm{cm}^{-6}}{10^{20} \, \mathrm{cm}^{-6}} \approx 1 \, \mathrm{V}$ b)  $W_{dep} \approx \sqrt{\frac{2\varepsilon_s \phi_{bi}}{q N_d}} = \left(\frac{2 \times 12 \times 8.85 \times 10^{-14} \times 1}{1.6 \times 10^{-19} \times 10^{17}}\right)^{1/2} = 0.12 \, \mu \mathrm{m}$ c)  $|x_N| \approx W_{dep} = 0.12 \, \mu \mathrm{m}$ d)  $|x_P| = |x_N| N_d / N_a = 1.2 \times 10^{-4} \, \mu \mathrm{m} = 1.2 \, \text{Å} \approx 0$ 







**EXAMPLE:** If the slope of the line in the previous slide is  $2x10^{23} F^{-2} V^{-1}$ , the intercept is 0.84V, and A is 1  $\mu$ m<sup>2</sup>, find the lighter and heavier doping concentrations  $N_l$  and  $N_h$ .

### Solution:

$$N_{I} = 2/(slope \times q\varepsilon_{s}A^{2})$$

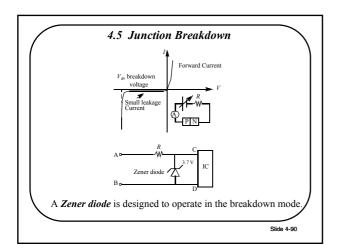
$$= 2/(2 \times 10^{23} \times 1.6 \times 10^{-19} \times 12 \times 8.85 \times 10^{-14} \times 10^{-8} \text{ cm}^{2})$$

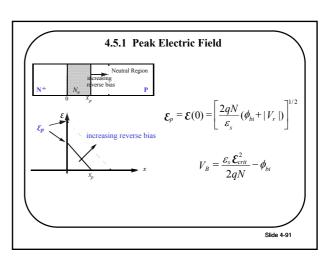
$$= 6 \times 10^{15} \text{ cm}^{-3}$$

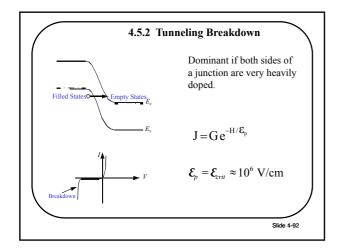
$$\phi_{bi} = \frac{kT}{q} \ln \frac{N_h N_I}{n_i^2} \implies N_h = \frac{n_i^2}{N_I} e^{\frac{q\phi_{hi}}{kT}} = \frac{10^{20}}{6 \times 10^{15}} e^{\frac{0.84}{0.026}} = 1.8 \times 10^{18} \text{ cm}^{-3}$$

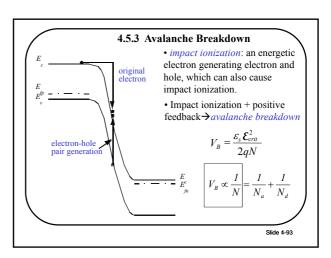
• Is this an accurate way to determine  $N_l$ ?  $N_h$ ?

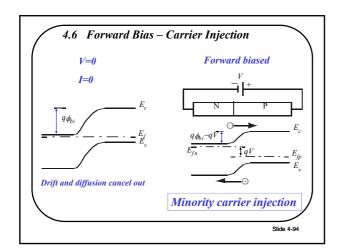
Slide 4-89

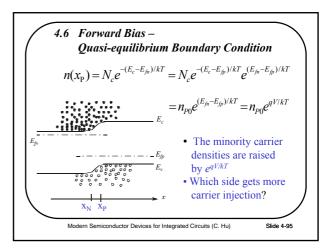






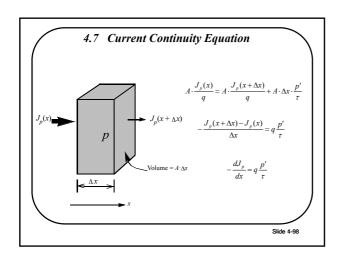


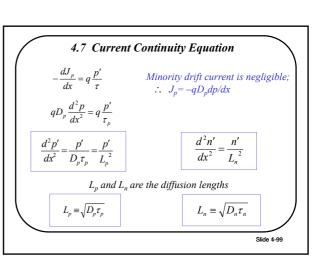


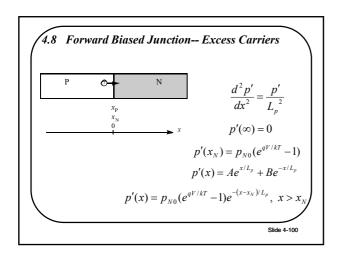


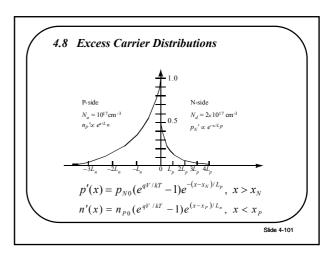
# 4.6 Carrier Injection Under Forward Bias—Quasi-equilibrium Boundary Condition $n(x_p) = n_{p_0} e^{qV/kT} = \frac{n_i^2}{N_a} e^{qV/kT}$ $p(x_p) = p_{N_0} e^{qV/kT} = \frac{n_i^2}{N_d} e^{qV/kT}$ $n'(x_p) \equiv n(x_p) - n_{p_0} = n_{p_0} (e^{qV/kT} - 1)$ $p'(x_N) \equiv p(x_N) - p_{N_0} = p_{N_0} (e^{qV/kT} - 1)$ Slide 4-96

## EXAMPLE: Carrier Injection A PN junction has $N_a = 10^{19} \text{cm}^{-3}$ and $N_d = 10^{16} \text{cm}^{-3}$ . The applied voltage is 0.6 V. Question: What are the minority carrier concentrations at the depletion-region edges? Solution: $n(x_p) = n_{p_0} e^{qV/kT} = 10 \times e^{0.6/0.026} = 10^{11} \text{ cm}^{-3}$ $p(x_N) = p_{N_0} e^{qV/kT} = 10^4 \times e^{0.6/0.026} = 10^{14} \text{ cm}^{-3}$ Question: What are the excess minority carrier concentrations? Solution: $n'(x_p) = n(x_p) - n_{p_0} = 10^{11} - 10 = 10^{11} \text{ cm}^{-3}$ $p'(x_N) = p(x_N) - p_{N_0} = 10^{14} - 10^4 = 10^{14} \text{ cm}^{-3}$









EXAMPLE: Carrier Distribution in Forward-biased PN Diode

N-type  $N_d = 5 \times 10^{17} \text{ cm}^3$   $D_p^0 = 12 \text{ cm}^2/s$   $\tau_p^0 = 1 \text{ µs}$ • Sketch n'(x) on the P-side.  $n'(x_p) = n_{p_0}(e^{qV/kT} - 1) = \frac{n_i^2}{N_a}(e^{qV/kT} - 1) = \frac{10^{20}}{10^{17}}e^{0.6/0.026} = 10^{13} \text{ cm}^{-3}$ N-side

N-side

N-side

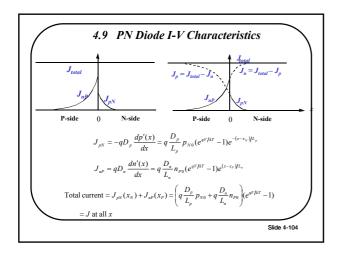
N-side

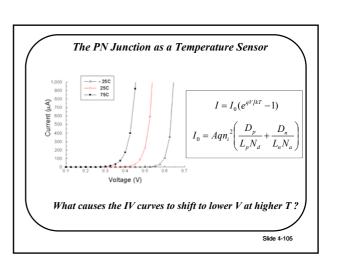
N-side

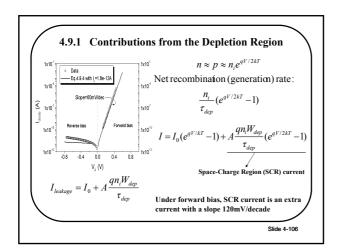
N-side

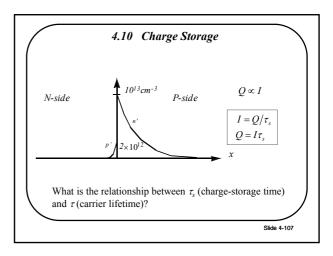
N-side

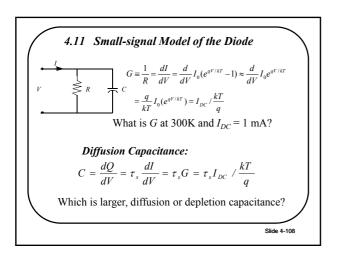
• How does  $L_n$  compare with a typical device size?  $L_n = \sqrt{D_n \tau_n} = \sqrt{36 \times 2 \times 10^{-6}} = 85 \, \mu \text{m}$ • What is p'(x) on the P-side?

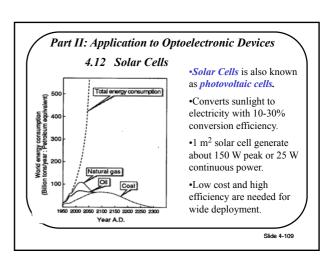


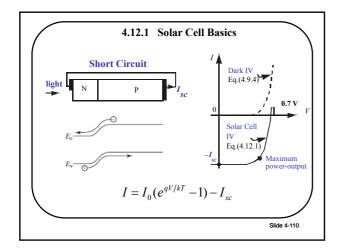


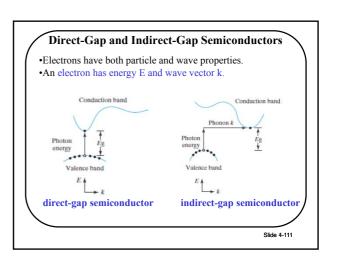


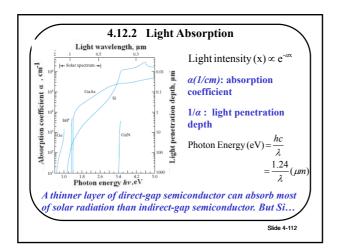


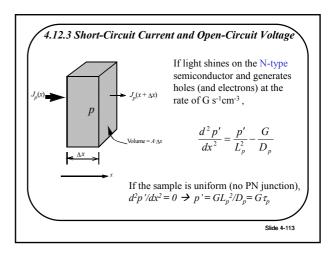


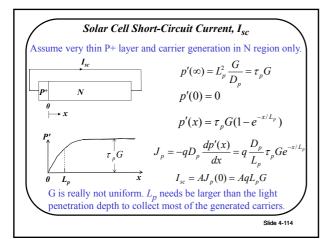


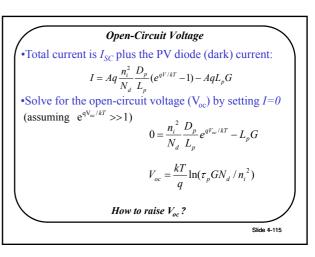


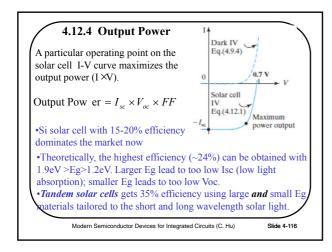


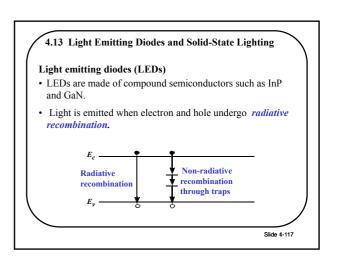


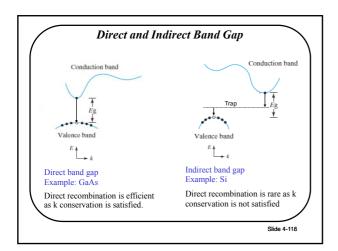


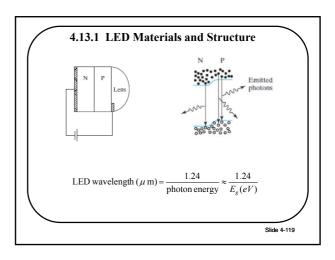


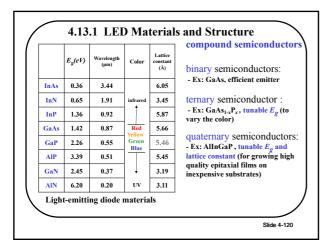


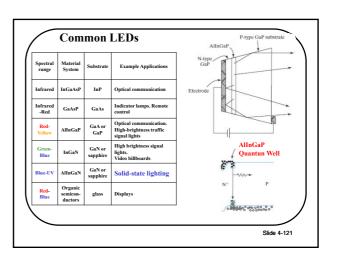


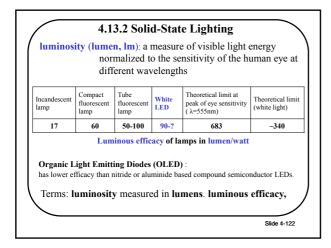


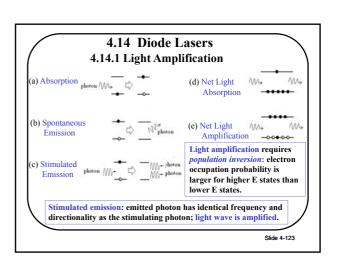


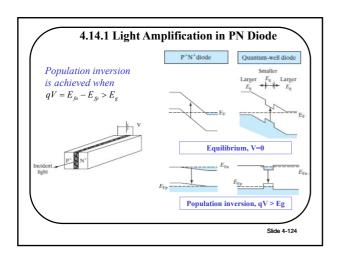


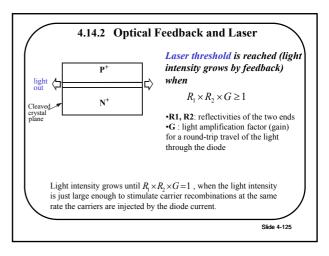












4.14.2 Optical Feedback and Laser Diode • Distributed Bragg reflector (DBR) reflects light with multi-layers of semiconductors. ·Vertical-cavity surfaceemitting laser (VCSEL) is shown on the left. Ouantum-well laser has smaller threshold current because fewer carriers (n+) GaAs substrate are needed to achieve population inversion in the small volume of the thin small-Eg well. Modern Semiconductor Devices for Integrated Circuits (C. Hu) Slide 4-126

### 4.14.3 Laser Applications

Red diode lasers: CD, DVD reader/writer

Blue diode lasers: Blu-ray DVD (higher storage density) 1.55 µm infrared diode lasers: Fiber-optic communication

### 4.15 Photodiodes

Photodiodes: Reverse biased PN diode. Detects photogenerated current (similar to Isc of solar cell) for optical communication, DVD reader, etc.

Avalanche photodiodes: Photodiodes operating near avalanche breakdown amplifies photocurrent by impact ionization

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## **Tunnel Diode** Several important devices for high-frequency applications use the instabilities that occur in semiconductors. An important type of instability involves negative conductance. Here we shall concentrate on three of the most commonly used negative conductance devices. Esaki or tunnel diodes, which depend on quantum-mechanical tunneling; transit-time diodes, which depend on semipartion of carrier injection and transit-time effects and Gunn diodes, which depend on the transfer of electrons from a high-mobility state to a low-mobility state. Each is a two-terminal device that can be operated in a negative conductance mode to provide amplification or oscillation at microwave frequencies in a proper circuit. The tunnel diode is a p-n junction device that operates in certain regions of its I-V characteristic by the quantum mechanical tunneling of electrons through the potential barrier of the junction. (See Sections 2.4.4 and 5.4.1.) The tunneling process for reverse current is essentially the Zener effect, although negligible reverse bias is needed to initiate the process in tunnel diodes. As we shall see in this section, the tunnel diode (often called the Esaki diode after L. Esaki, who received the Nobel Prize in 1973 for his TUNNEL DIODES Slide 1-128

### 10.1.1 Degenerate Semiconductors

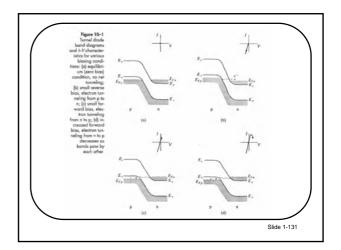
10.1.1 Degenerate Semiconductors

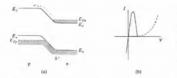
Thus far, we have discussed the properties of relatively pure semiconductors; any impurity doping represented a small fraction of the total atomic density of the material. Since the few impurity atoms were so widely spaced throughout the sample, we could be confident that no charge transport could take place within the donor or acceptor levels themselves. At high doping, the impurities are so close together that we can no longer consider the donor level as being composed of discrete, noninteracting energy states. Instead, the donor states form a band, which may overlap the bottom of the conduction band. If the conduction-band electron concentration n exceeds the effective density of states  $N_c$ , the Fermi level is no longer within the band gap, but lies within the conduction band. When this occurs, the material is called degenerate n-type. The analogous case of degenerate p-type material occurs when the acceptor concentration is very high and the Fermi level lies in the valence band. We recall that the energy states below  $E_p$  are mostly filled and states above  $E_p$  are empty, except for a small distribution dictated by the Fermi statistics. Thus, in a degenerate n-type sample, the region between  $E_e$  and  $E_p$  is for the most part filled with electrons, and in a degenerate p-type sample, the region between  $E_e$  and  $E_p$  is almost completely filled with holes.

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A p-n junction between two degenerate semiconductors is illustrated in terms of energy bands in Fig. 10-1a. This is the equilibrium condition, for which the Fermi level is constant throughout the junction. We notice that  $E_{F,p}$  lies below the valence-band edge on the p side, and  $E_{F,p}$  is above the conduction-band edge on the n side. Thus, the bands must overlap on the energy scale in order for  $E_F$  to be constant. This overlapping of bands is very important; it means that, with a small forward or reverse bias, filled states and empty states appear opposite each other, separated by essentially the width of the depletion region. If the metallurgical junction is sharp, the depletion region will be very narrow for such high-doping concentrations, and the electric field at the junction will be quite large. Hence, the conditions for electron tunneling are met: filled and empty states separated by a narrow potential barrier of finite height. In Fig. 10-1, the bands are shown filled to the Fermi level for convenience of illustration, with the understanding that a distribution is implied. Since the bands overlap under equilibrium conditions, a small reverse bias (Fig. 10-1b) allows electron tunneling from the filled valence-band states below  $E_{F_P}$  to the empty conduction-band states above  $E_{F_P}$ . This condition is similar to the Zener effect, except that no bias is required to create the condition of overlapping bands. As the reverse bias is increased,  $E_{F_P}$  continues to move down the energy scale with respect to  $E_{F_P}$  placing more filled states on the p side opposite empty states on the n side. Thus, the tunneling of electrons from p to n increases with increasing reverse bias. The resulting conventional current is opposite to the electron flow—that is, from n to p, At

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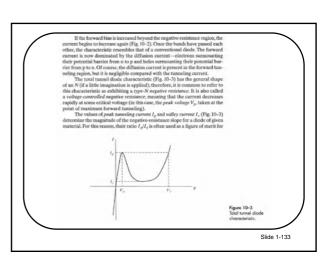




a region of negative slope; that is, the dynamic resi-negative-resistance region is useful in oscillators.

e dV/dI is negative. This

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the tunnel diode. Similarly, the ratio  $V_{\mu}/V_f$  is a measure of the voltage spread between the two positive-resistance regions. The negative resistance of the tunnel diode can be used in a number of ways to achieve oscillation and other circuit functions. The fact that the tunneling process does not present the time delays of drift and diffusion makes the tunnel diode a natural choice for cortain high-speed circuits. However, the tunnel diode has not achieved widespread application, because of its relatively low current operation and competition from other devices.

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